## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Kie Y. Ahn et al.

Title:

EVAPORATED Laaio3 FILMS FOR GATE DIELECTRICS

Docket No.:

1303.046US1<sup>/</sup>

Filed:

February 20, 2002

Examiner:

Unknown

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Serial No.: 10/081439

Due Date: N/A

Group Art Unit: 2818

We are transmitting herewith the following attached items (as indicated with an "X"):

A return postcard. X

A Supplemental Information Disclosure Statement (2 pgs.), Form 1449 (2 pgs.), and copies of 30 cited X documents.

If not provided for in a separate paper filed herewith, Please consider this a PETITION FOR EXTENSION OF TIME for sufficient number of months to enter these papers and please charge any additional fees or credit overpayment to Deposit Account No. 19-0743.

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

Customer Number 21186

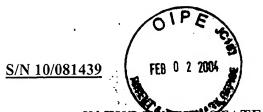
Atty: David R. Cochran

Reg. No. 46,632

CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on this **30** day of January, 2004.

SCHWEGMAN, LUNDBERG, WOESSNER & KLUTH, P.A.

(GENERAL)



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## SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

In compliance with the duty imposed by 37 C.F.R. § 1.56, and in accordance with 37 C.F.R. §§ 1.97 *et. seq.*, the enclosed materials are brought to the attention of the Examiner for consideration in connection with the above-identified patent application. Applicants respectfully request that this Supplemental Information Disclosure Statement be entered and the documents listed on the attached Form 1449 be considered by the Examiner and made of record. Pursuant to the provisions of MPEP 609, Applicants request that a copy of the 1449 form, initialed as being considered by the Examiner, be returned to the Applicants with the next official communication.

Pursuant to 37 C.F.R. §1.97(b), it is believed that no fee or statement is required with the Supplemental Information Disclosure Statement. However, if an Office Action on the merits has been mailed, the Commissioner is hereby authorized to charge the required fees to Deposit Account No. 19-0743 in order to have this Supplemental Information Disclosure Statement considered.

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Serial No :10/081439

Filing Date: February 20, 2002

Title: EVAPORATED LaAIO3 FILMS FOR GATE DIELECTRICS

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The Examiner is invited to contact the Applicants' Representative at the below-listed telephone number if there are any questions regarding this communication.

Respectfully submitted,

KIE Y. AHN ET AL.

By their Representatives,

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<del>\_\_</del>\_

Signature

Substitute for form 1449A/PTO Complete if Known INFORMATION DISCLOSURE 10/081439 **Application Number** STATEMENT BY APPLICANT February 20, 2002 Filing Date Ahn, Kie **First Named Inventor Group Art Unit** 2818 FEB 0 2 2004 Unknown **Examiner Name** Attorney Docket No: 1303.046US1 Sheet 1 of 2

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**EXAMINER** 

**DATE CONSIDERED** 

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